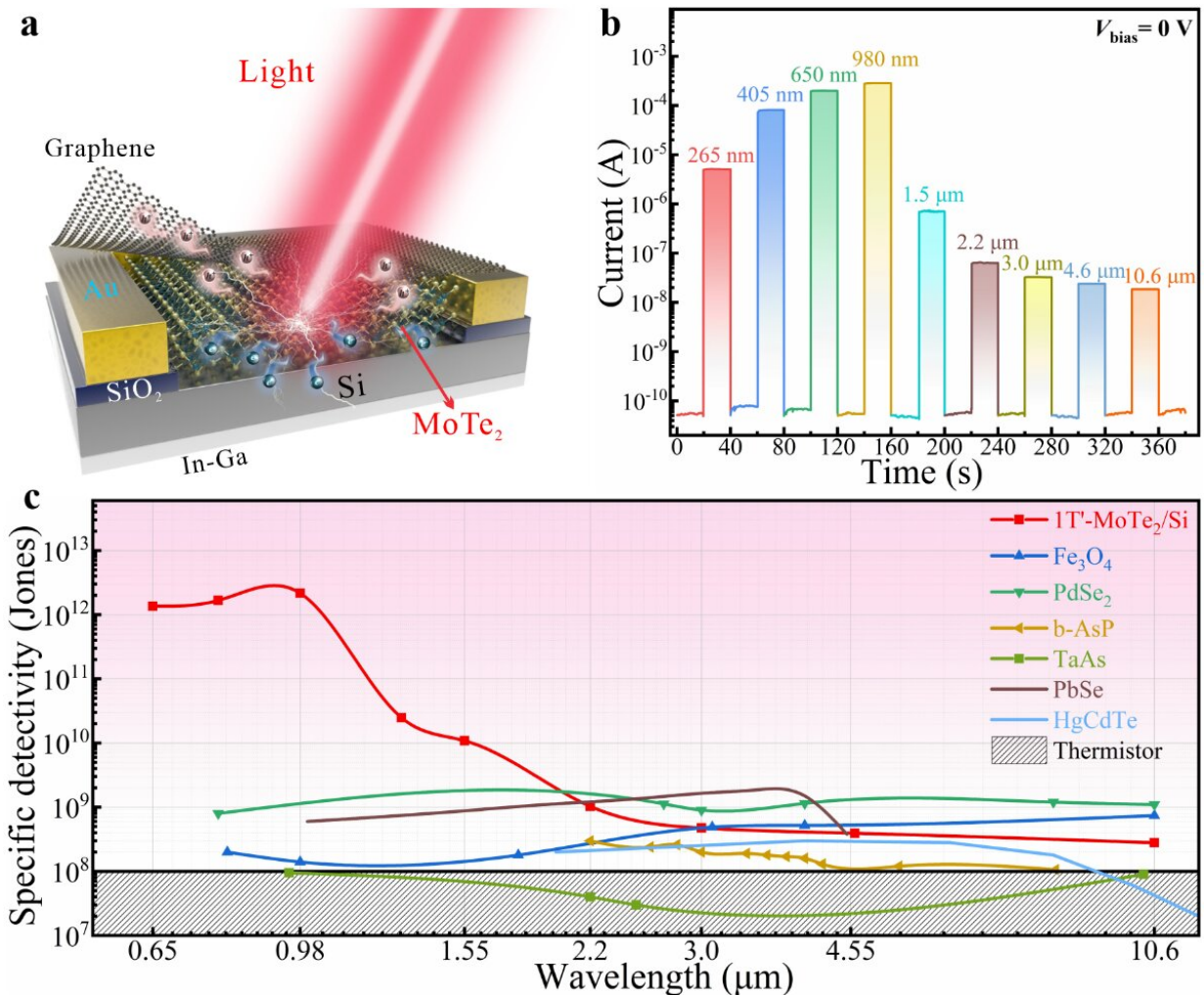


Wafer-scale 2D MoTe₂ layers enable highly-sensitive broadband integrated infrared detectors

January 5 2023



a, Schematic illustration of a graphene/1T'-MoTe₂/Si Schottky junction device.
b, Time-dependent photoresponse properties to pulsed light illumination in a

broad spectral band. c, Comparison of the room-temperature specific detectivity of the Gr/1T'-MoTe₂/Si Schottky junction device with other devices. Credit: Di Wu, Chenguang Guo, Longhui Zeng, Xiaoyan Ren, Zhifeng Shi, Long Wen, Qin Chen, Meng Zhang, Xin Jian Li, Chong-Xin Shan, and Jiansheng Jie

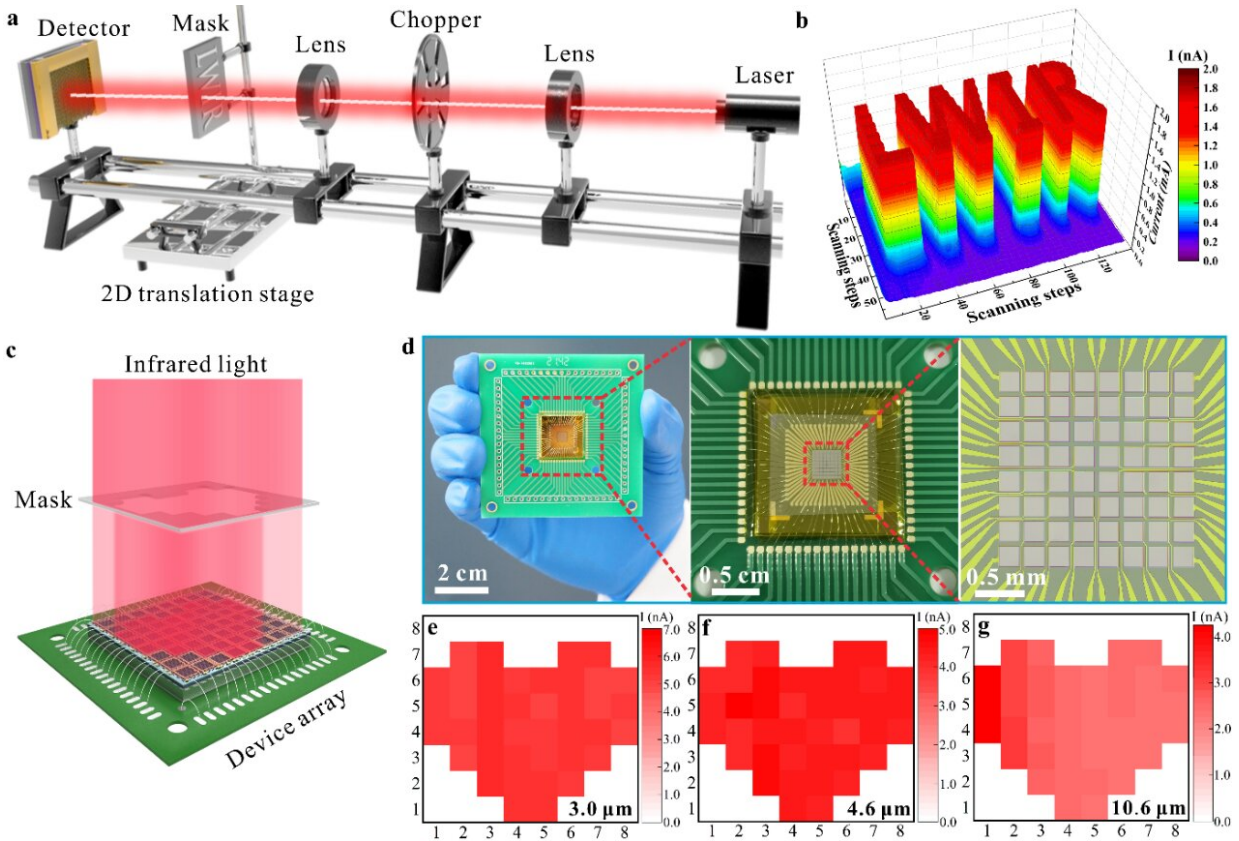
Detection in multiple infrared (IR) regions spanning from short- and mid- to long-wave IR plays an important role in diverse fields from scientific research to wide-ranging technological applications, including target identification, imaging, remote monitoring, and gas sensing. Currently, state-of-the-art IR photodetectors are mainly dominated by conventional narrow bandgap semiconductors including In_{1-x}Ga_xAs, InSb, and Hg_{1-x}Cd_xTe, operating in short-wave IR (SWIR, 1-3 μm), mid-wave IR (MWIR, 3-6 μm), and long-wave IR (LWIR, 6-15 μm) spectral bands, respectively.

Notably, these [photodetectors](#) not only rely on high-temperature growth process of [raw materials](#) and complex processing technique, but also suffer from the cryogenic cooling conditions with time-consuming and high power consumption. Moreover, there are several remaining technological challenges, such as poor complementary metal-oxide-semiconductor (CMOS) compatibility, bulky module size and low efficiency, which severely restrict the wider application of these detectors.

In a new paper published in *Light Science & Application*, Professors Di Wu and Xinjian Li from Zhengzhou University, Dr. Longhui Zeng from the University of California-San Diego, and Prof. Jiansheng Jie from Soochow University have demonstrated a facile thermal-assisted tellurization route for the van der Waals (vdW) growth of wafer-scale phase-controlled 2D MoTe₂ layers. The type-II Weyl semimetal 1T'-MoTe₂ layers were directly deposited on prepatterned Si substrate to

fabricate in-situ a 1T'-MoTe₂/Si vertical Schottky junction. The high-quality Schottky junction interface and vertical device structure with graphene electrodes ensure efficient carrier transport and reduce carrier recombination, enabling the detector to achieve an ultrabroadband detection range of up to 10.6 μm and a room-temperature specific detectivity of over 10^8 Jones in the mid-infrared region. The wafer-scale 2D MoTe₂ layers also enable the integrated device array to be successfully implemented for high-resolution, uncooled, mid-infrared imaging.

In this study, a pre-deposited Mo film as a precursor was transformed to 2D MoTe₂ layer via vdW growth mechanism through a direct thermal-assisted tellurization process. As a matter of fact, the phase transition of MoTe₂ is highly dependent on the growth time. By controlling the growth time, 2-inch 2H and 1T'- MoTe₂ layers with good uniformity were obtained, respectively. By virtue of the facile and scalable thermal-assisted tellurization strategy, the thickness of the 2D MoTe₂ layers could be precisely tailored by tuning the initial Mo film thickness.



a A schematic of a single-pixel based IR imaging system. b IR imaging of “LWIR” patterns under $10.6\ \mu\text{m}$ at room-temperature. c A schematic of IR imaging measurement based on devices array. d Photographs of an 8×8 $1\text{T}'$ - MoTe_2/Si Schottky junction device array. e-g The imaging results of the “heart” pattern under 3.0 , 4.6 , and $10.6\ \mu\text{m}$, respectively. Credit: Di Wu, Chenguang Guo, Longhui Zeng, Xiaoyan Ren, Zhifeng Shi, Long Wen, Qin Chen, Meng Zhang, Xin Jian Li, Chong-Xin Shan, and Jiansheng Jie

The vdW growth of the large-area 2D MoTe_2 layers offers more flexibility for the development of high-sensitivity optoelectrical devices. In light of this, a $1\text{T}'$ - MoTe_2/Si vertical Schottky junction device was developed by the in-situ vdW growth of $1\text{T}'$ - MoTe_2 layers on a pre-patterned Si substrate. To ensure the efficient carrier collection, monolayer graphene was selected as a top transparent contact with a $1\text{T}'$ -

MoTe₂ layer. The photodetector demonstrates high-sensitive self-powered ultrabroadband detection performance with a detection range of up to 10.6 μm and a large room-temperature specific detectivity of over 10⁸ Jones in the mid-infrared (MIR) range. The obtained room-temperature specific detectivity is superior to the most 2D material-based IR detectors and some commercial detectors.

Given the superior IR detection capability of the photodetector, the room-temperature IR imaging was further explored with the Gr/1T'-MoTe₂/Si Schottky junction device. The photocurrent mapping image of "LWIR" pattern with a large current contrast ratio over 10 and sharp edges was obtained from an individual detector under the IR illumination of 10.6 μm at room temperature. Furthermore, the large-scale uniform 2D MoTe₂ layer enables the fabrication of an 8 × 8 1T'-MoTe₂/Si Schottky junction device array for IR imaging application.

Upon MIR laser illumination, the large difference between the currents of the exposed and unexposed pixels results in a high-resolution heart-shaped image with large current ratios of 100, 68, and 51 for 3.0, 4.6, and 10.6 μm laser illumination at room-temperature, respectively. Such excellent room-temperature imaging capability with good homogeneity of the device array gives this finding great promise for MIR imaging applications. The wafer-scale growth of 2D MoTe₂ layers compatible with Si technology shows great potential for next-generation on-chip Si CMOS systems with low-power consumption and low-cost production.

More information: Di Wu et al, Phase-controlled van der Waals growth of wafer-scale 2D MoTe₂ layers for integrated high-sensitivity broadband infrared photodetection, *Light: Science & Applications* (2023). [DOI: 10.1038/s41377-022-01047-5](https://doi.org/10.1038/s41377-022-01047-5)

Provided by Chinese Academy of Sciences

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